

Docket No.: M4065.0239/P239

(PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Larry Hillyer et al.

Application No.: 09/653,561

Art Unit: 2812

Filed: August 31, 2000

Examiner: Ha T. Nguyen

For: METHOD AND MATERIAL FOR

REMOVING ETCH RESIDUE FROM HIGH ASPECT RATIO CONTACT SURFACES

## **AMENDMENT TO NON-FINAL OFFICE ACTION**

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

## **INTRODUCTORY COMMENTS**

In response to the Office Action mailed June 6, 2005, please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 17 of this paper.